

# Iridium-Catalyzed Borylation of Primary C(sp<sup>3</sup>)-H Bonds



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Supervisor: Prof. Ma Shengming

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2.1 Borylation of activated substrates

2.2 Borylation of unactivated substrates

2.3 Borylation of methane

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Summary and outlook

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## Background

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2.1 Borylation of activated substrates

2.2 Borylation of unactivated substrates

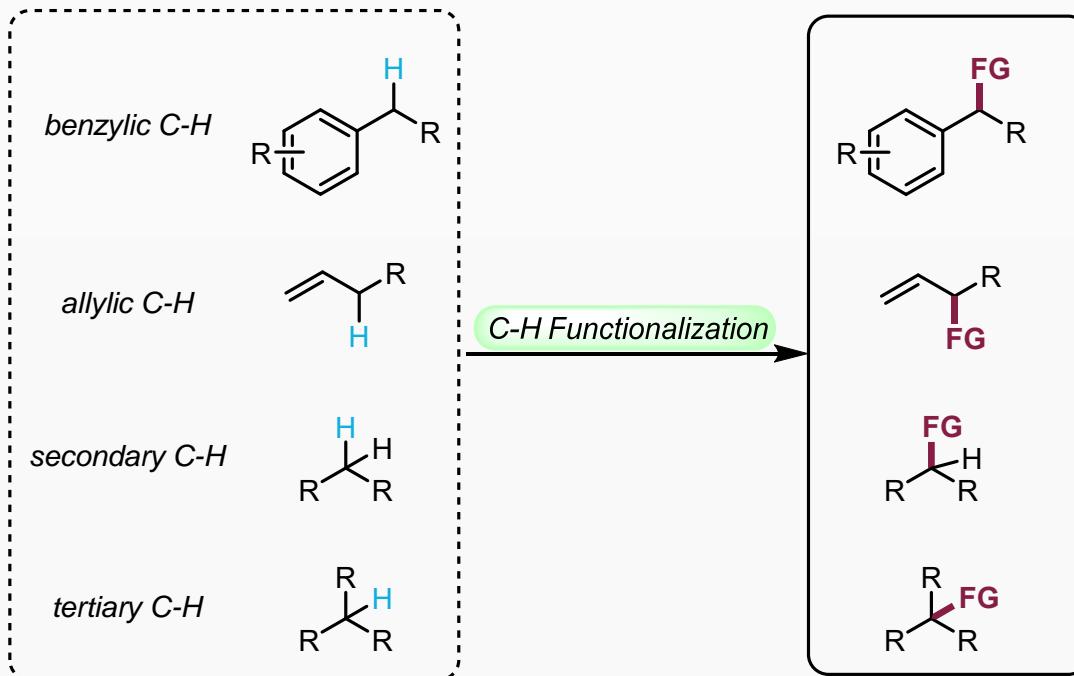
2.3 Borylation of methane

03 /

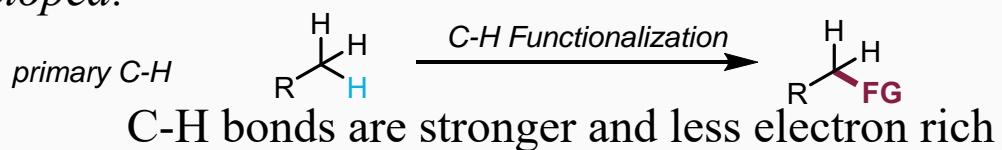
Summary and outlook

## Background

*Well developed:*

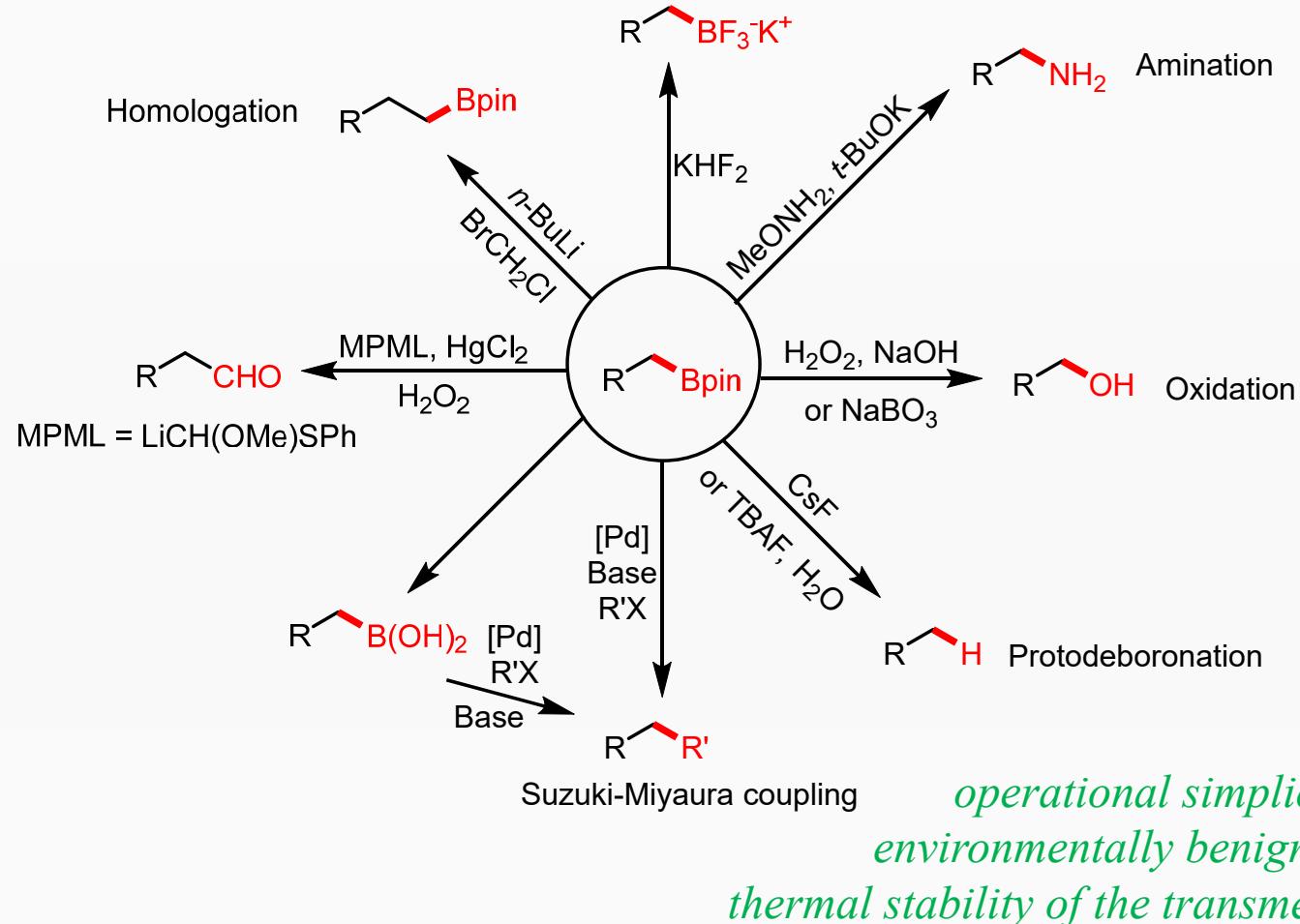


*Less developed:*



## Background

### Application of Alkylboron Reagents:

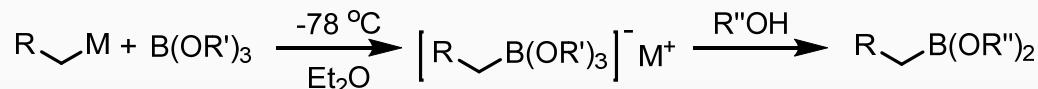


- Brown, H. C. *et al.*, *Pure & Appl. Chem.* **1987**, *59*, 879.  
Aggarwal, V. K. *et al.*, *Chem. Eur. J.* **2011**, *17*, 13124.  
Sigman, M. S. *et al.*, *Chem. Rev.* **2011**, *111*, 1417.  
Morken, J. P. *et al.*, *Synlett* **2018**, *29*, 1749.

## Background

### *Traditional Synthesis of Alkylboron Reagents:*

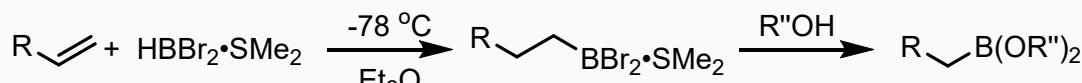
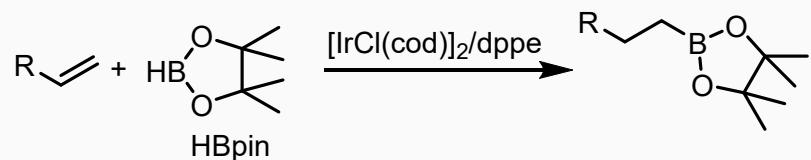
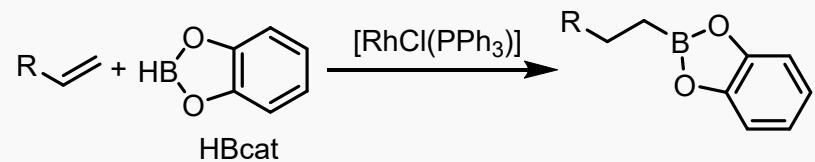
#### (1) From *Grignard and Lithium Reagents*



M = Li, MgX  
R''OH = H<sub>2</sub>O, alcohol or diol

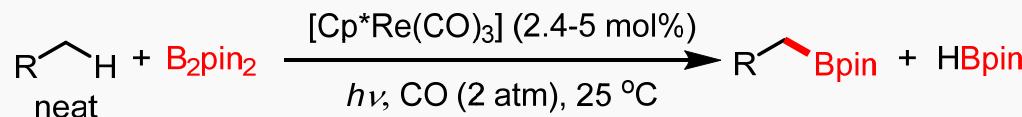
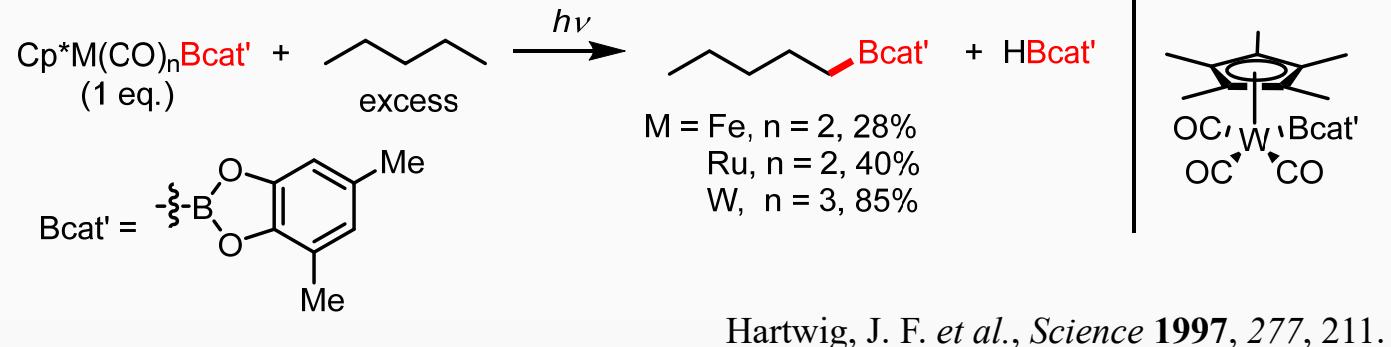
*Cons:* Multistep synthetic sequences  
Functionalized precursor  
Limited functional group compatibility

#### (2) via *Hydroboration*

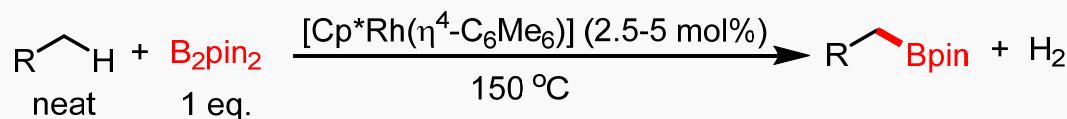


R''OH = H<sub>2</sub>O, alcohol or diol

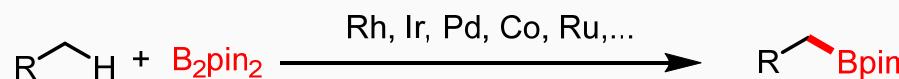
## Background



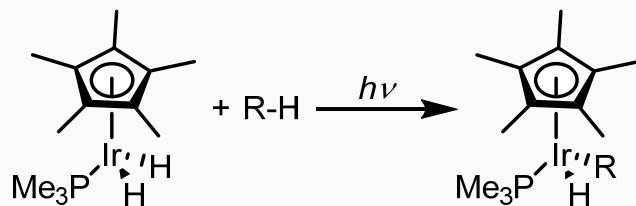
Hartwig, J. F. et al., *Angew. Chem., Int. Ed.* **1999**, 38, 3391.



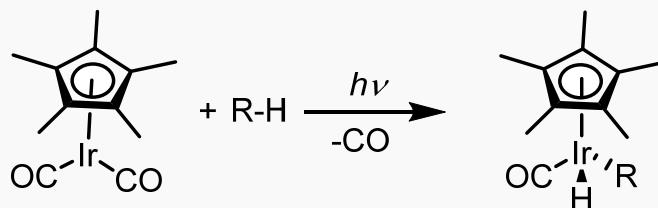
Hartwig, J. F. et al., *Science* **2000**, 287, 1995.



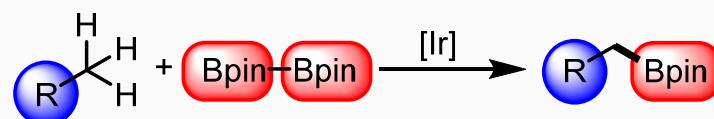
## Background



Bergman, R. G. et al., *J. Am. Chem. Soc.* **1982**, *104*, 352.



Graham, W. A. G. et al., *J. Am. Chem. Soc.* **1982**, *104*, 3723.  
Graham, W. A. G. et al., *J. Am. Chem. Soc.* **1983**, *105*, 7190.



# CONTENT >>

01 /

Background

02 /

2.1 Borylation of activated substrates

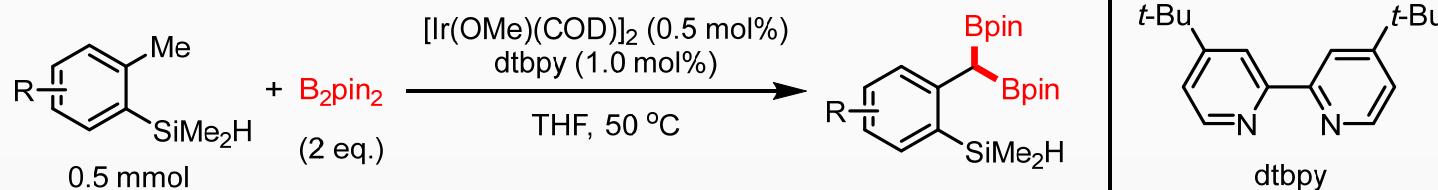
2.2 Borylation of unactivated substrates

2.3 Borylation of methane

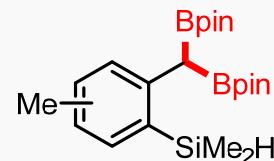
03 /

Summary and outlook

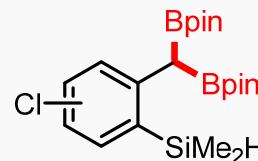
## Borylation of activated substrates--Benzylic C-H



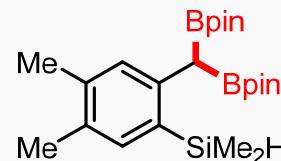
selected examples:



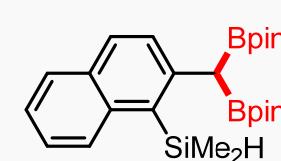
*o*-Me: 90% (12 h)  
*m*-Me: 84% (6 h)  
*p*-Me: 96% (2 h), 93%<sup>a</sup> (12 h)



*o*-Me: 85% (12 h)  
*m*-Me: 80% (12 h)  
*p*-Me: 87% (12 h)

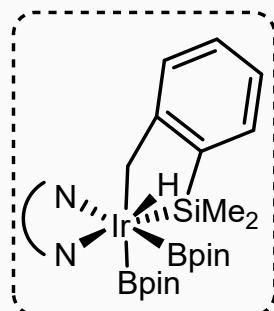


84% (12 h)

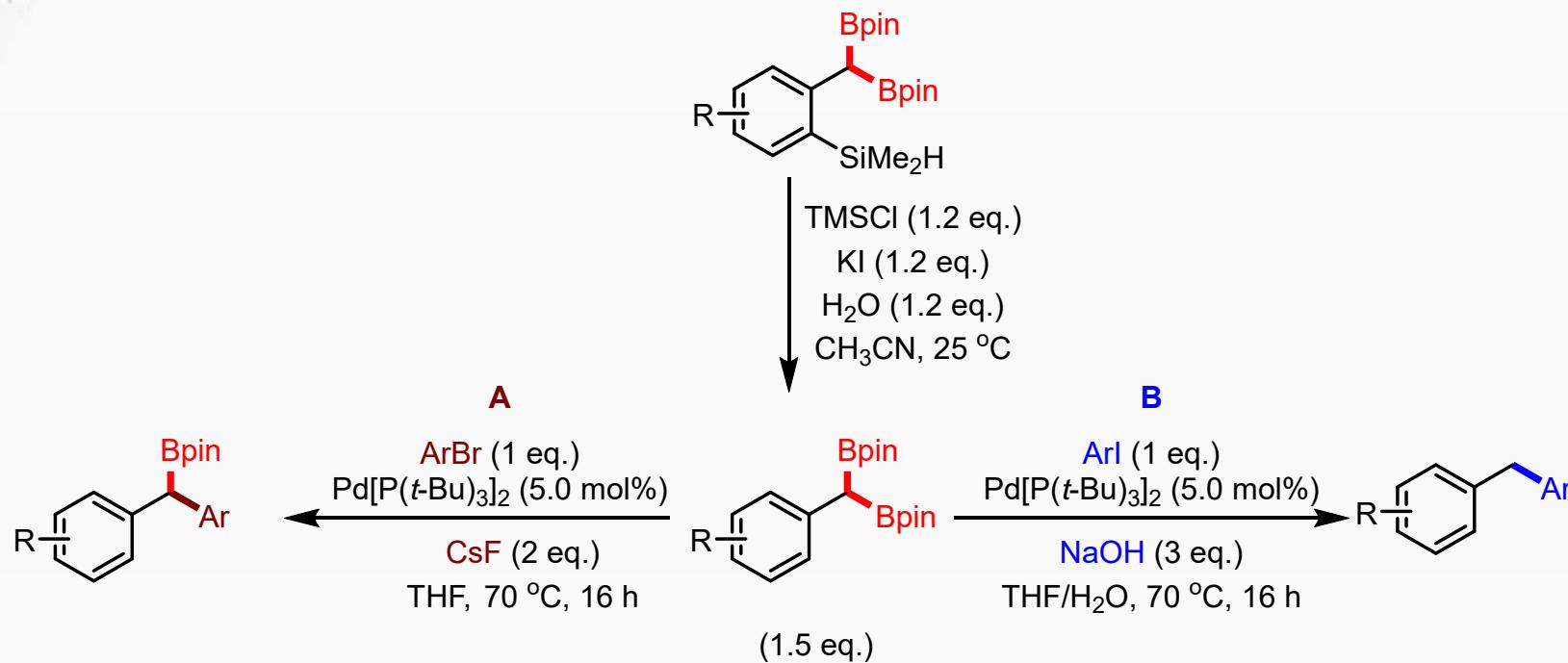


80% (12 h)

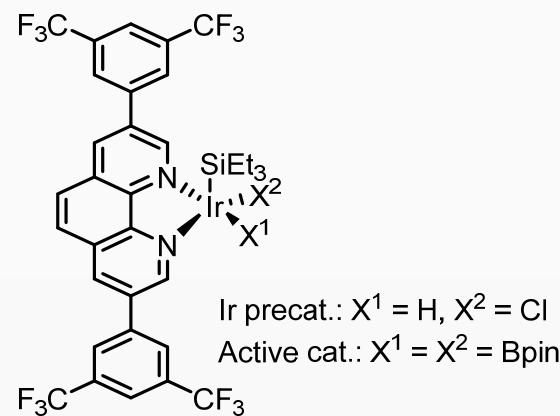
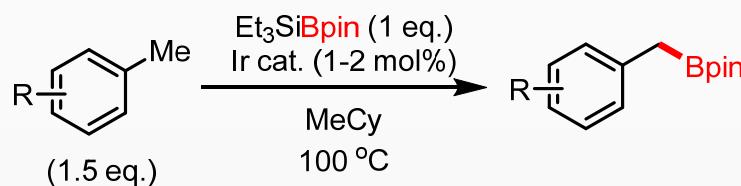
<sup>a</sup> 5 mmol scale



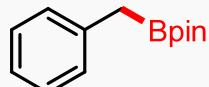
## Borylation of activated substrates--Benzyl C-H



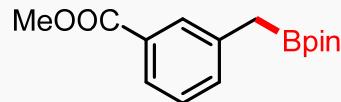
## Borylation of activated substrates--Benzylic C-H



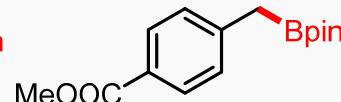
*selected examples:*



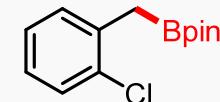
51%  
 $Bn:Ar = 9:1$



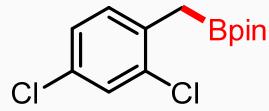
38%  
 $Bn:Ar = 2.7:1$



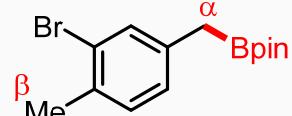
61%  
 $Bn:Ar = 23:1$



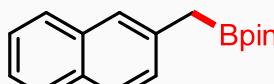
35%  
 $Bn:Ar = 3:1$



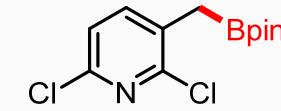
68%  
 $Bn:Ar > 99:1$



52%  
 $Bn:Ar > 99:1$   
 $\alpha:\beta = 6.3 : 1$

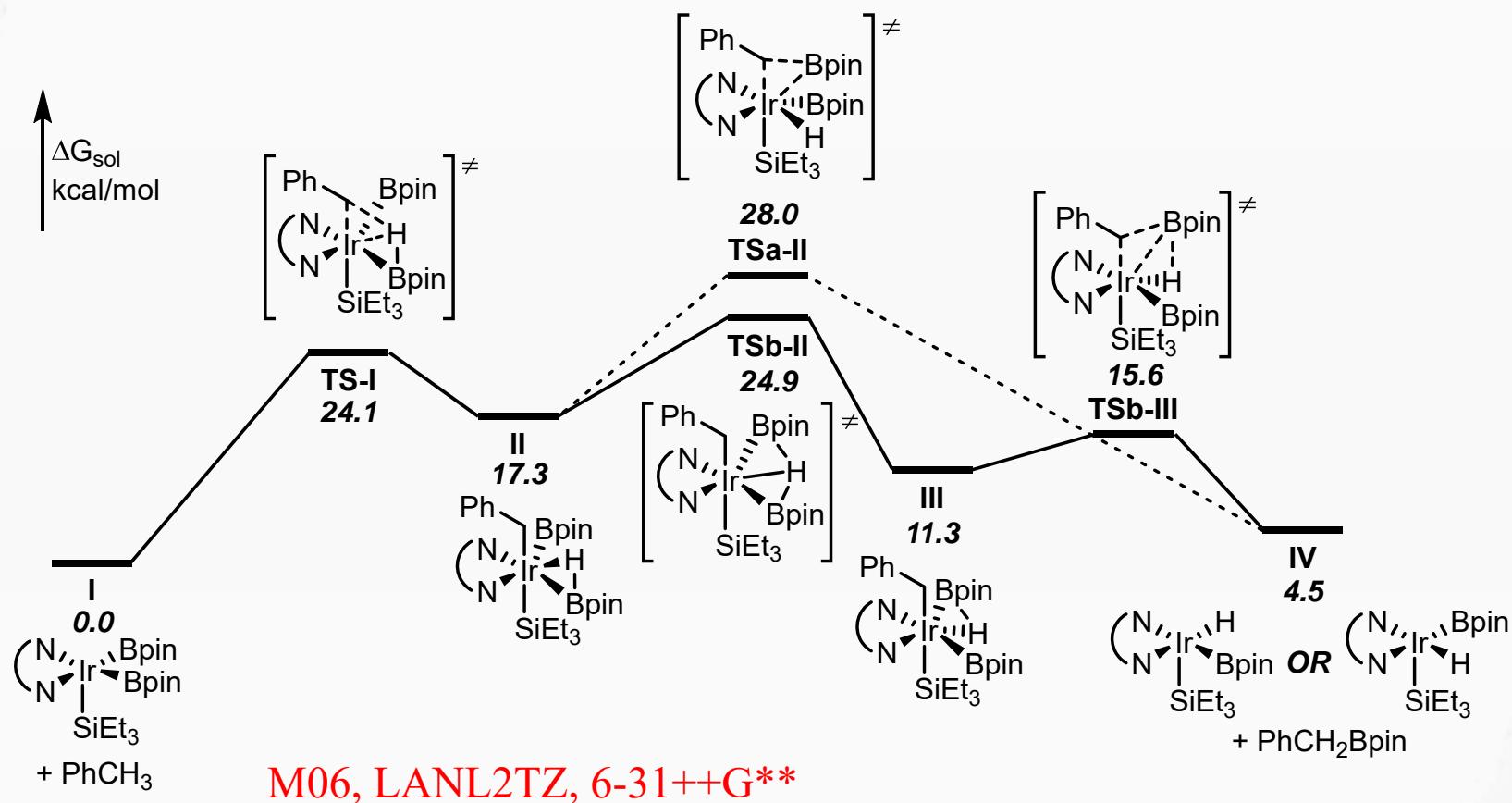


80%  
 $Bn:Ar = 19:1$



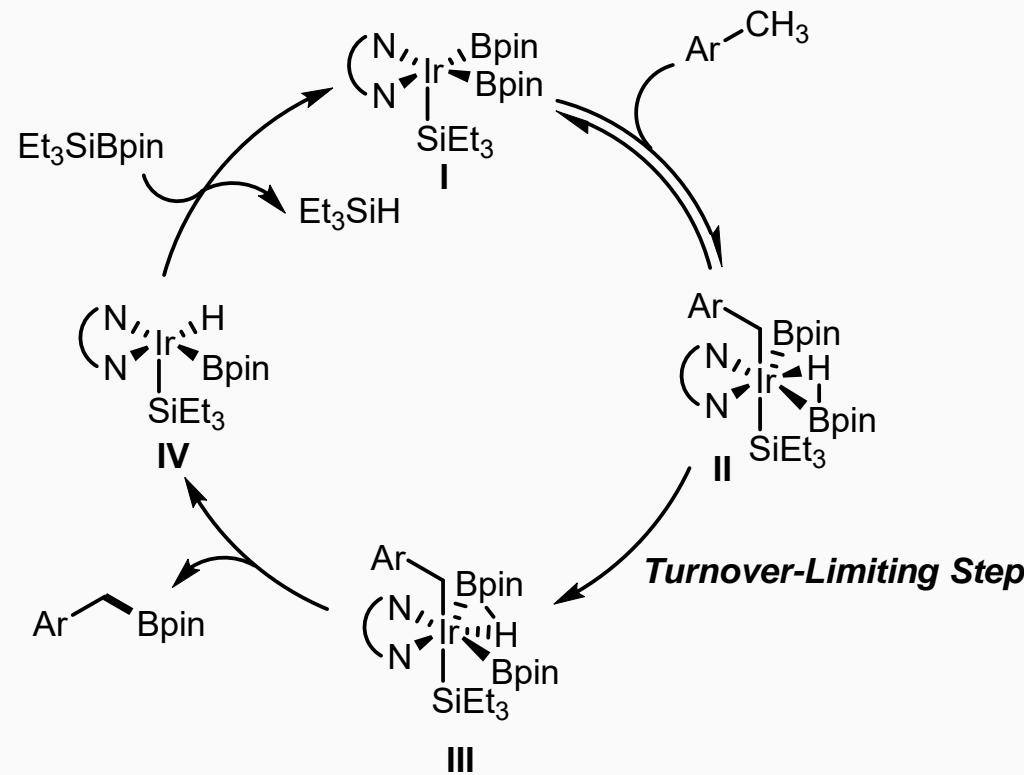
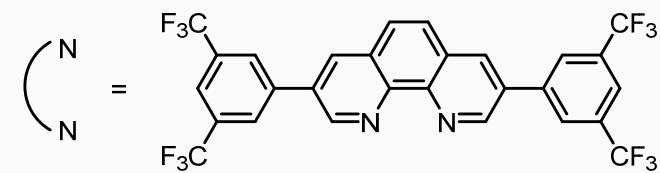
60%  
 $Bn:Ar = 4:1$

## Borylation of activated substrates--Benzyl C-H



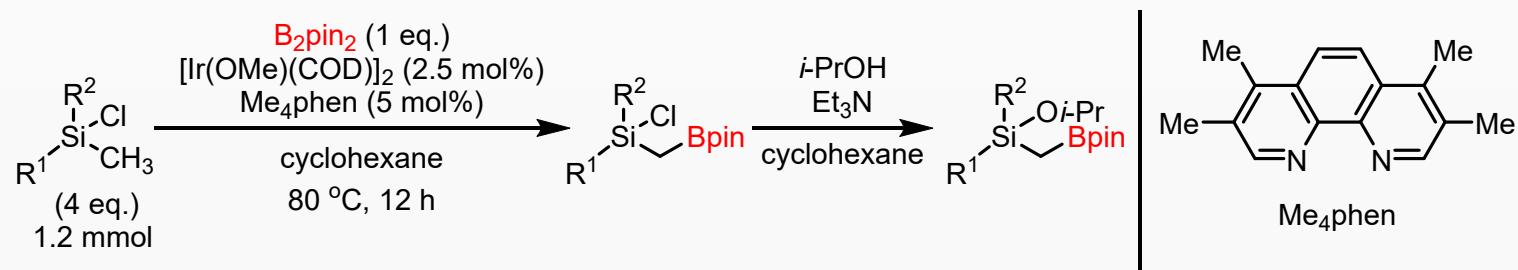
Hartwig, J. F. et al., *J. Am. Chem. Soc.* **2015**, *137*, 8633.

## Borylation of activated substrates--Benzyl C-H

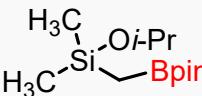
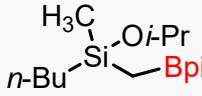
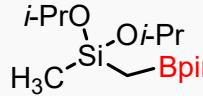
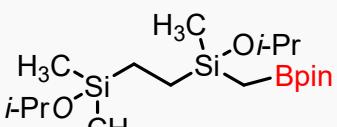
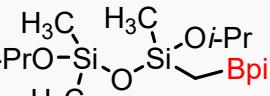


Hartwig, J. F. et al., *J. Am. Chem. Soc.* **2015**, *137*, 8633.

## Borylation of activated substrates--Silanes

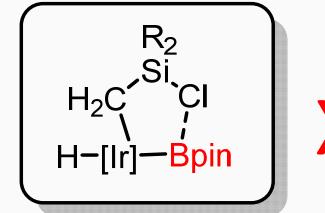


selected examples:

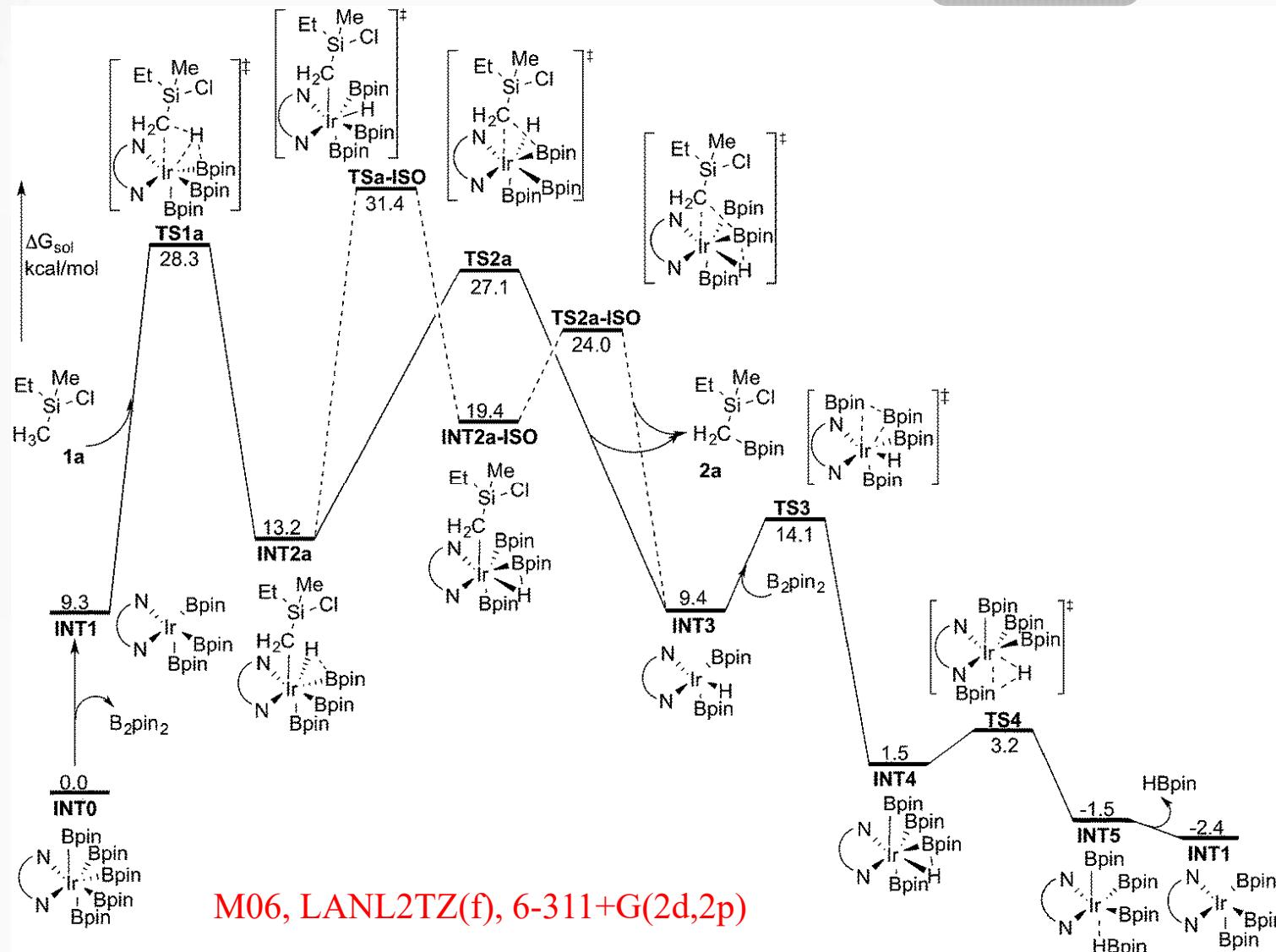
				
55 (93) <sup>a</sup> , 78 <sup>b</sup>	82%	58 (77) <sup>a</sup>	81%	67%

<sup>a</sup> <sup>1</sup>H NMR yield before isolated in the parentheses. <sup>b</sup> 120mmol scale.

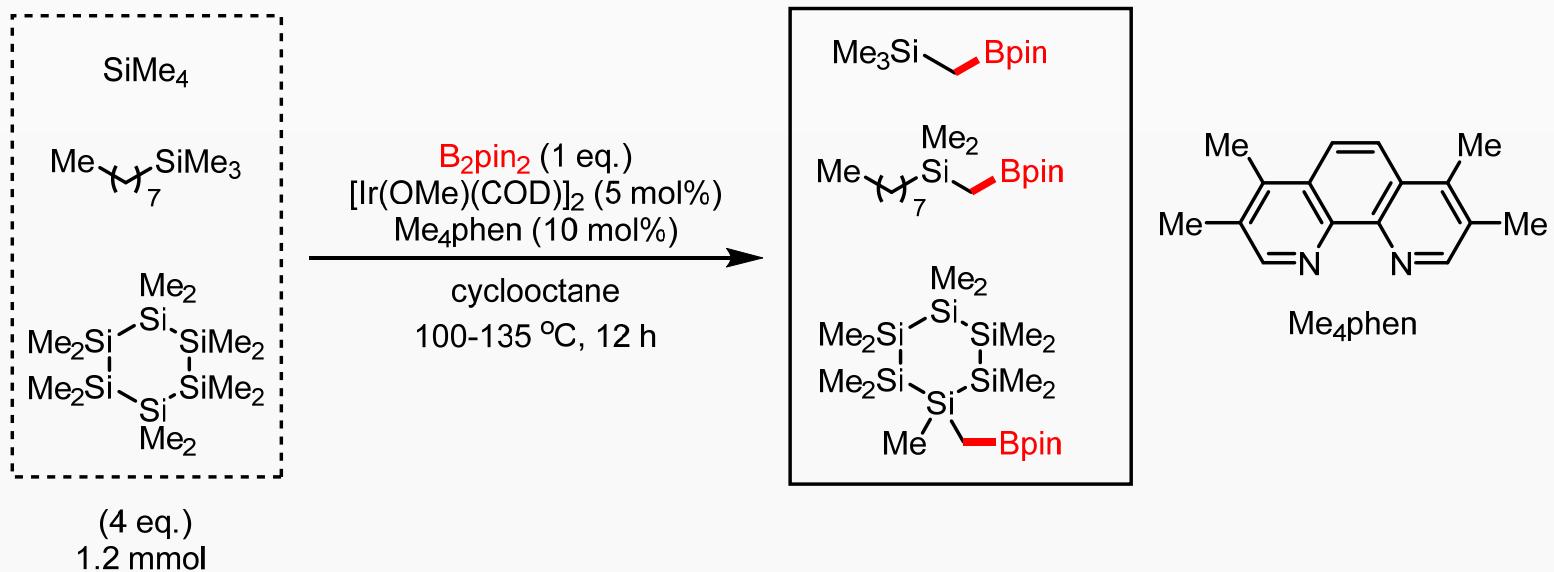
## Borylation of activated substrates--Silanes



X



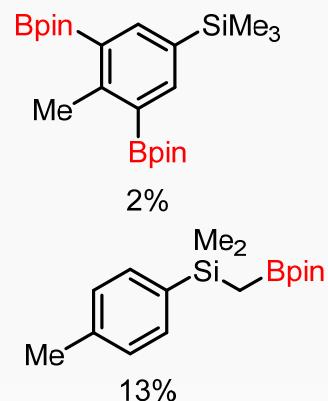
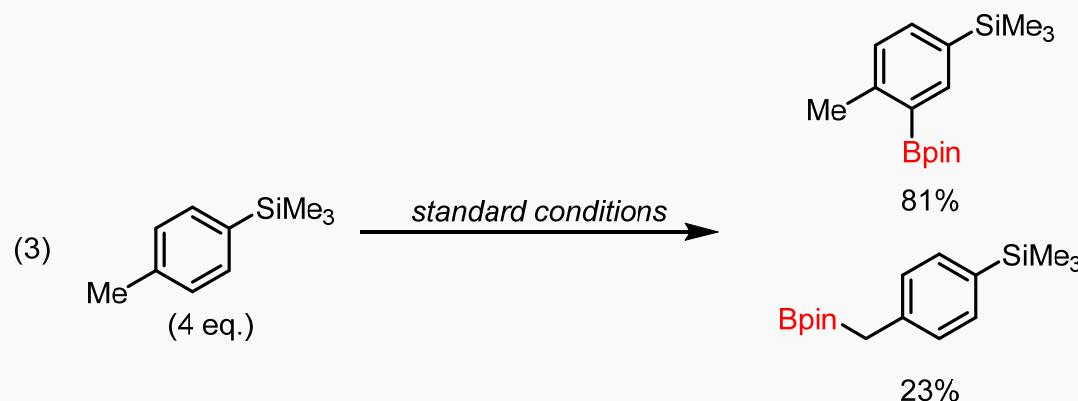
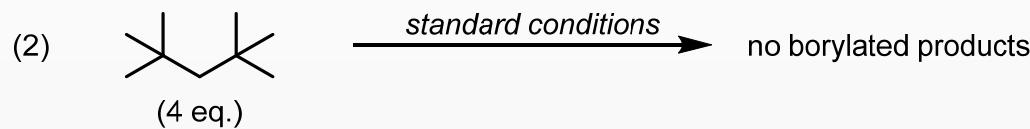
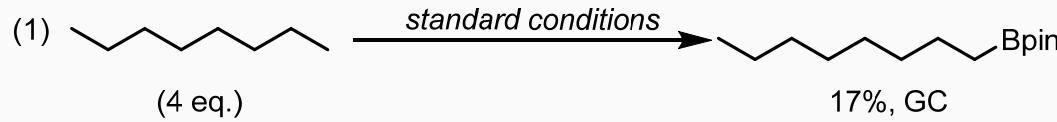
## Borylation of activated substrates--Silanes



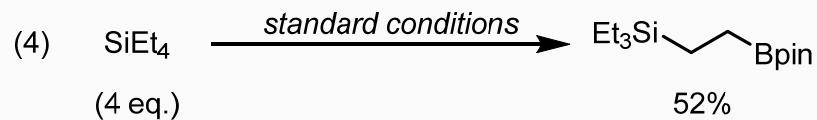
“*α-silyl effect*”  
*α-carbanion stabilizing effect of silicon*

## Borylation of activated substrates--Silanes

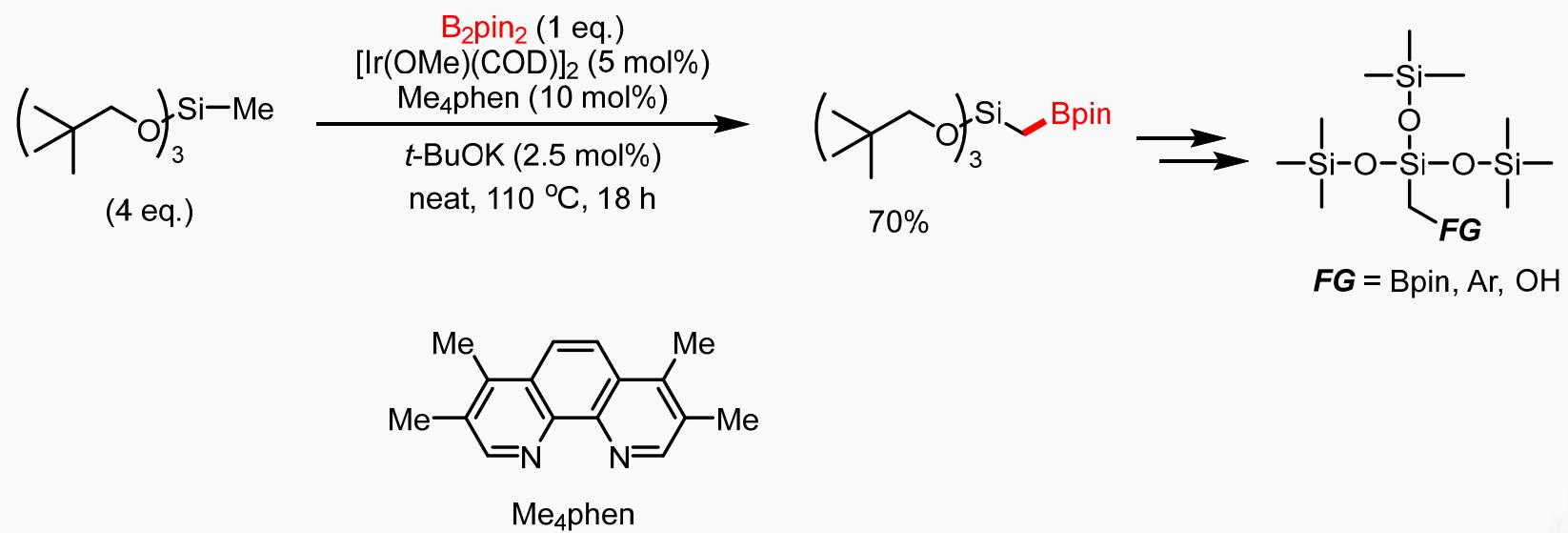
### Control experiments:



**Reactivity: Ar-H > Ar-CH<sub>3</sub> > Si-CH<sub>3</sub> > alkyl-CH<sub>3</sub>**

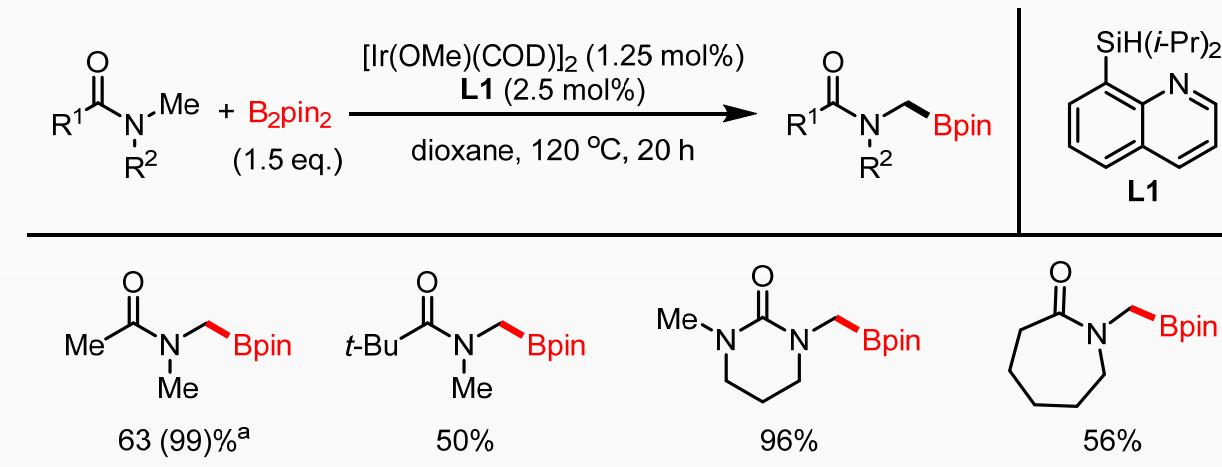


## Borylation of activated substrates--Silanes

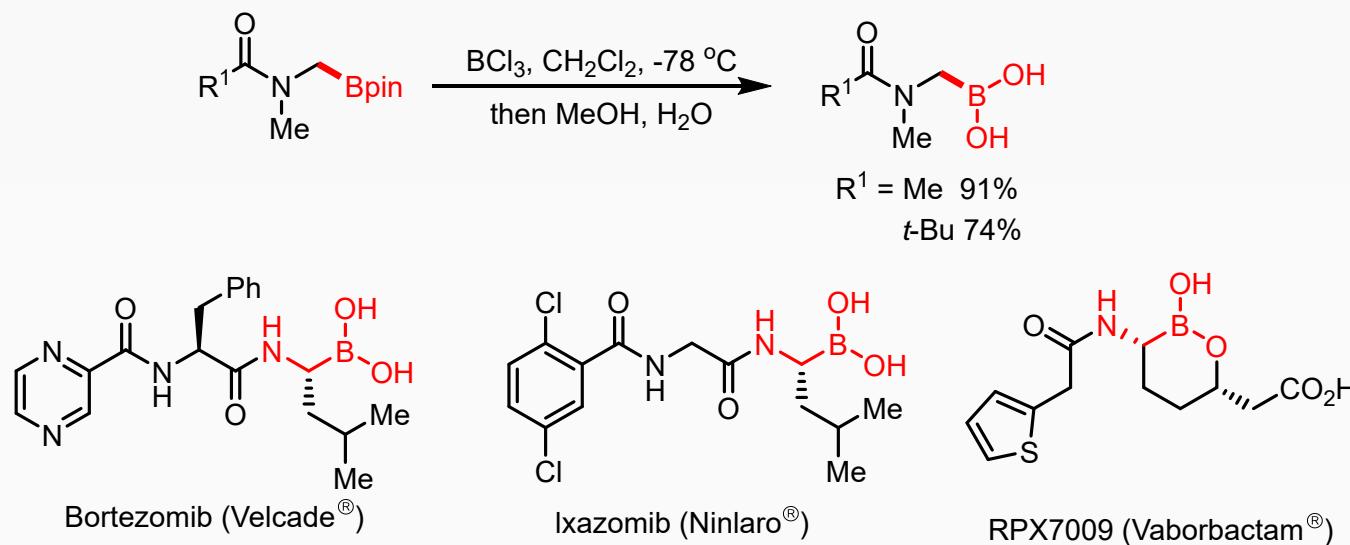


Suginome, M. *et al.*, *Organometallics* **2016**, *35*, 1601

## Borylation of activated substrates



<sup>a</sup>  $^1\text{H}$  NMR yield before isolated in the parentheses.



# CONTENT >>

01 /

Background

02 /

2.1 Borylation of activated substrates

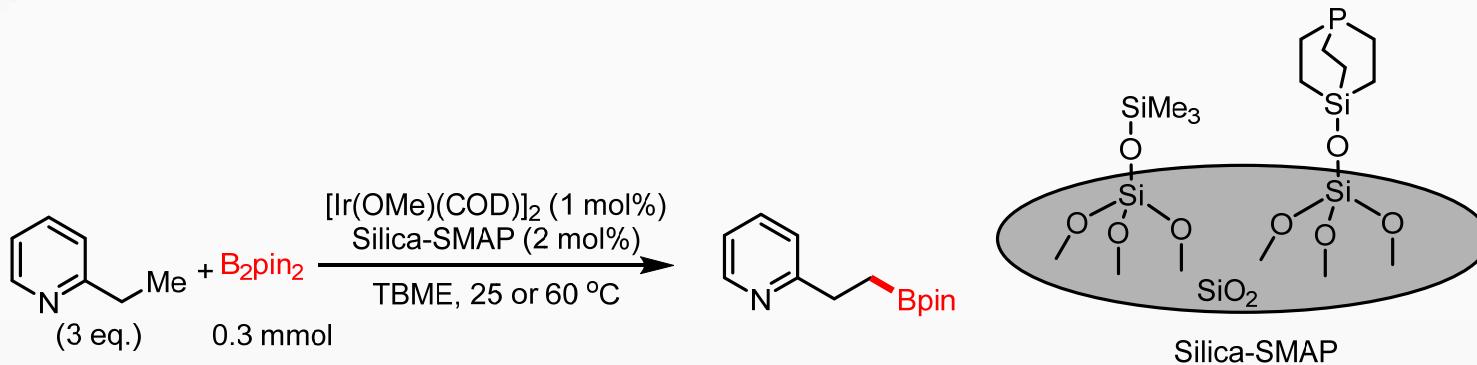
2.2 Borylation of unactivated substrates

2.3 Borylation of methane

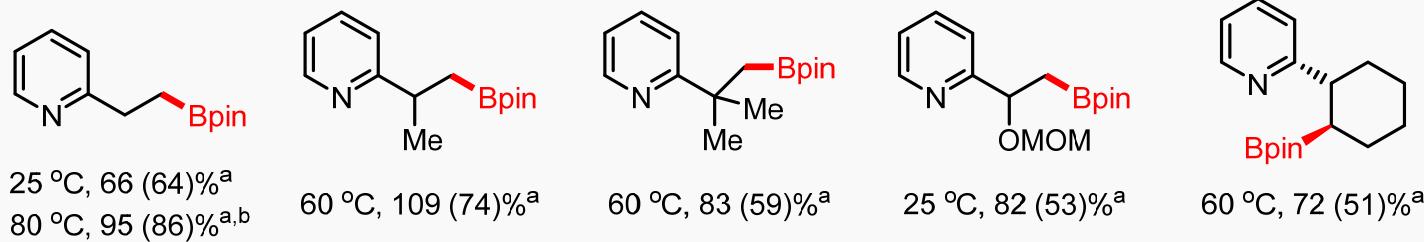
03 /

Summary and outlook

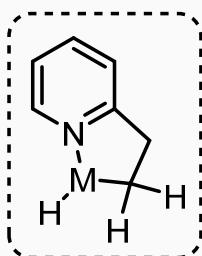
## Borylation of unactivated substrates



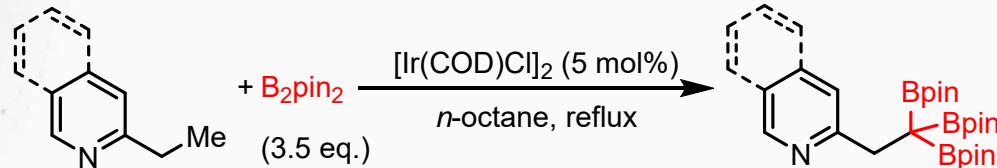
Selected examples:



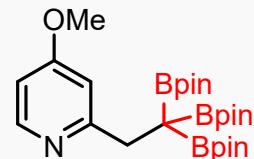
<sup>a</sup> isolated yield in the parentheses. <sup>b</sup> 5 mmol scale



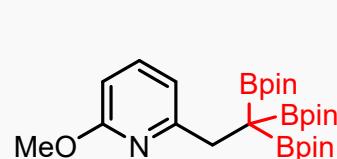
## Borylation of unactivated substrates



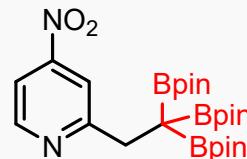
selected examples:



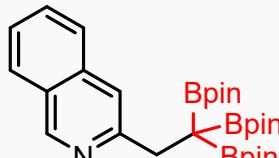
95 (81)%<sup>a</sup>



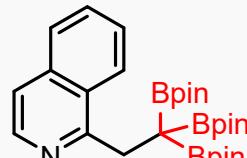
<1%



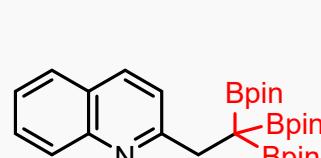
1%



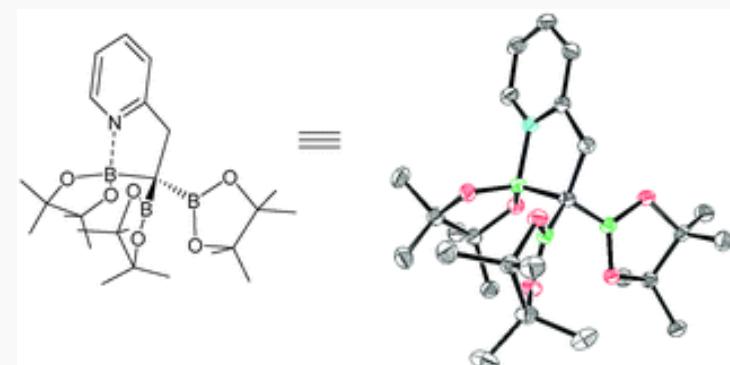
77 (52)%<sup>a</sup>



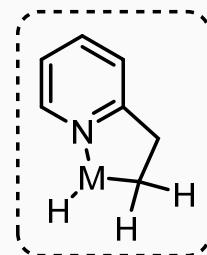
57 (44)%<sup>a</sup>



2%

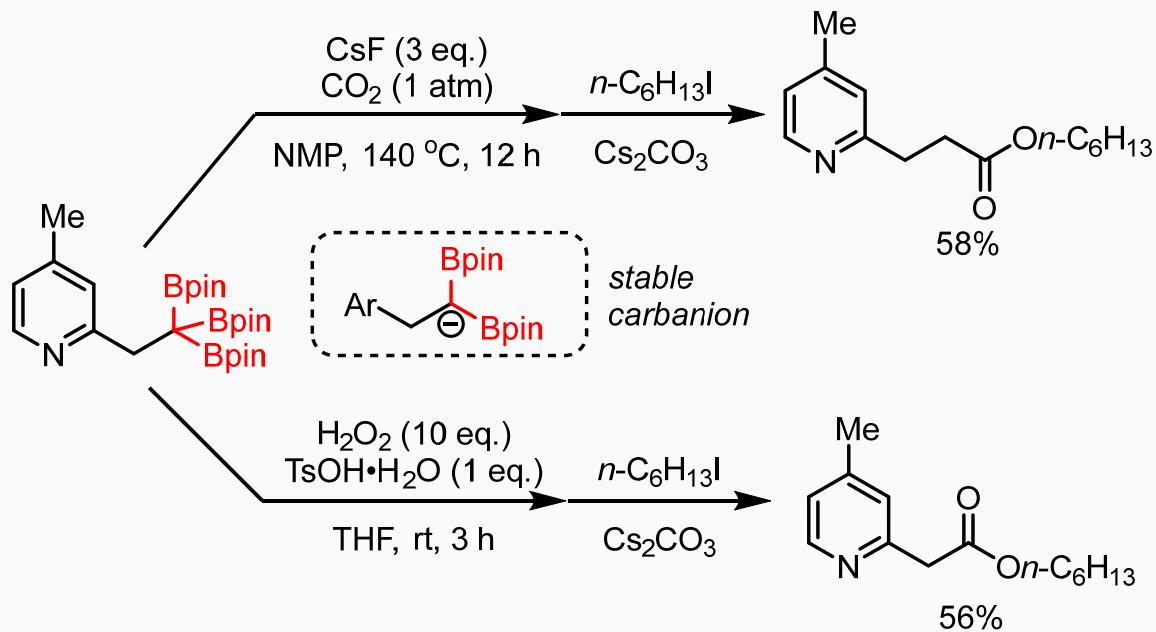


<sup>a</sup> isolated yield in the parentheses.

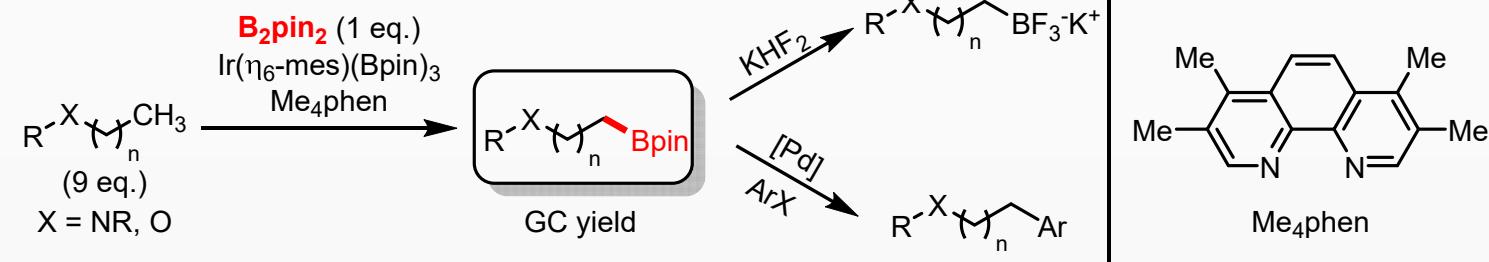


Sato, Y. et al., *Chem. Commun.* 2013, 49, 5601

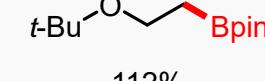
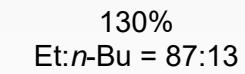
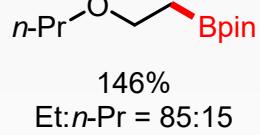
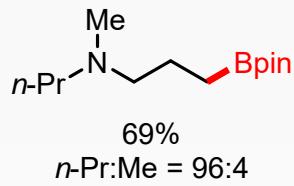
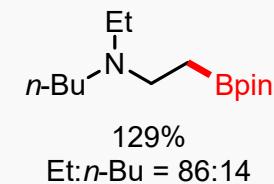
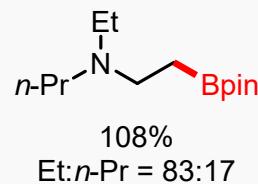
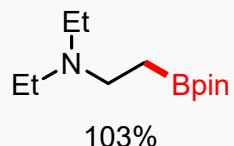
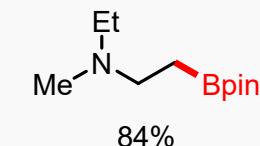
## Borylation of unactivated substrates



# Borylation of unactivated substrates

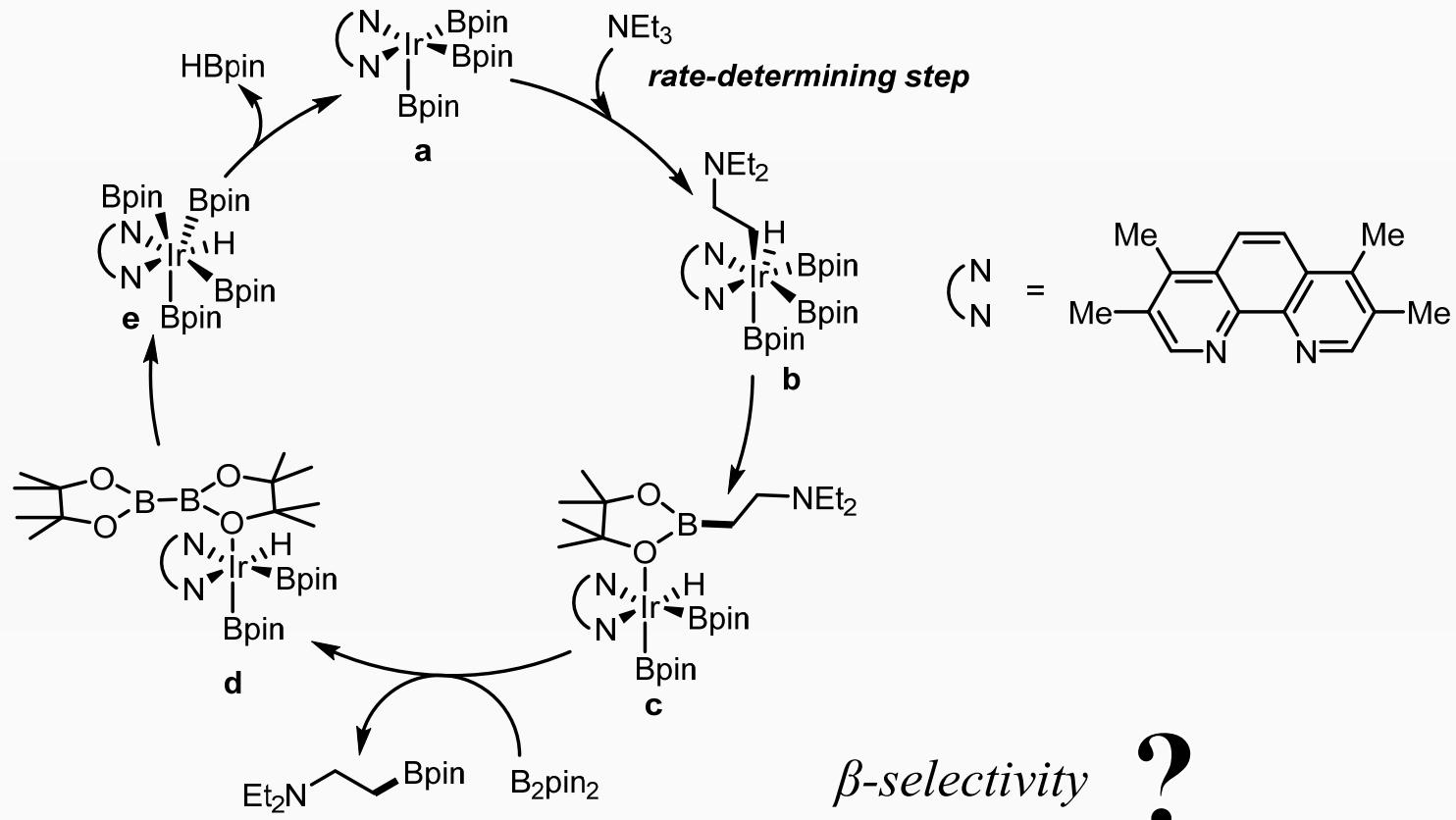


selected examples:



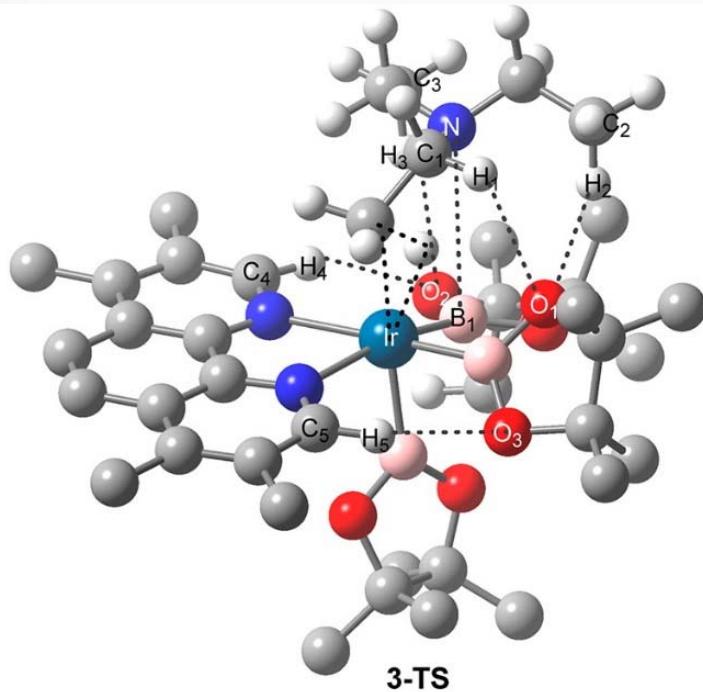
$\beta$ -selectivity

## Borylation of unactivated substrates

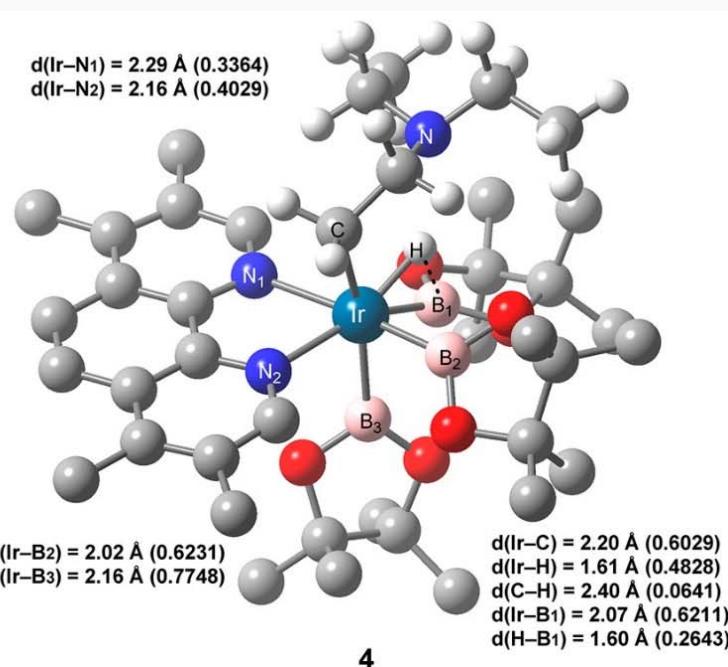


Hartwig, J. F. et al., *J. Am. Chem. Soc.* 2014, 136, 8755.

# Borylation of unactivated substrates

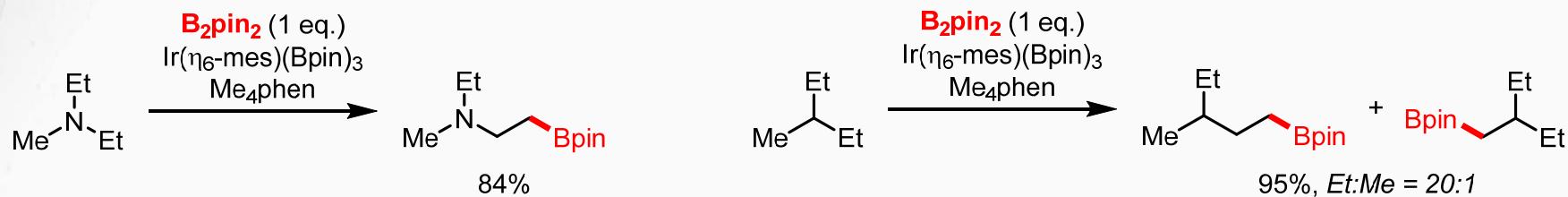


C-H···O interaction	$E_{\text{NBO}}(\text{C-H activation TS})$ (in kcal/mol)	$d(\text{C-O})$ (in Å)	$d(\text{O-H})$ (in Å)	$\angle(\text{C-H-O})$
C1-H1···O1	0.7	3.25	2.49	125.0°
C2-H2···O1	1.0	3.31	2.51	128.9°
C3-H3···O2	1.2	3.57	2.50	163.9°
C4-H4···O2	2.8	3.18	2.26	140.0°
C5-H5···O3	0.7	3.39	2.46	142.1°



1. Weak Lewis acid-base interaction
2. C-H···O interaction

# Borylation of unactivated substrates

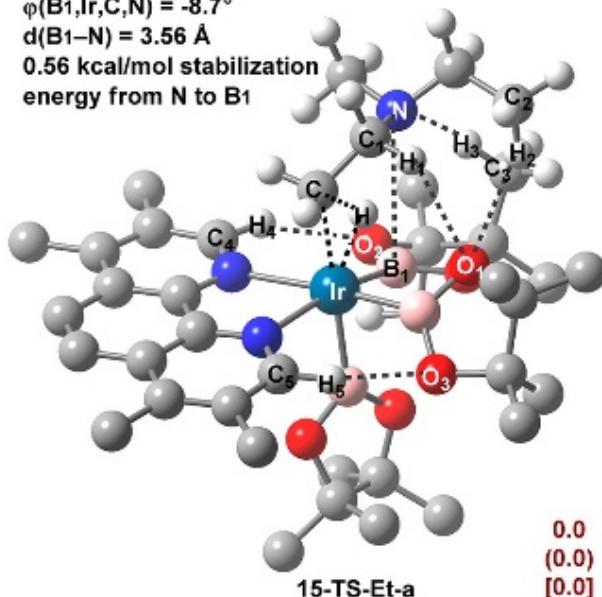


$$d(H-B_1) = 1.91 \text{ \AA} (0.1367)$$

$$\phi(B_1, Ir, C, N) = -8.7^\circ$$

$$d(B_1-N) = 3.56 \text{ \AA}$$

0.56 kcal/mol stabilization energy from N to B<sub>1</sub>



$$d(H-B_1) = 1.89 \text{ \AA} (0.1414)$$

$$\phi(B_1, Ir, C, N) = 11.8^\circ$$

$$d(B_1-N) = 3.73 \text{ \AA}$$

no stabilization energy from N to B<sub>1</sub>

$$\Delta G_{\text{amine}} \text{ 393 K} \\ (\Delta G_{\text{gas}} \text{ 393 K}) \\ [\Delta H_{\text{gas}} \text{ 393 K}] \\ \text{in kcal/mol}$$

$$15\text{-TS-Me-a} \quad 7.3 \quad (8.4) \quad [7.2]$$

1. Repulsive steric interactions

2. Weak Lewis acid-base interactions

3. C-H···O interactions



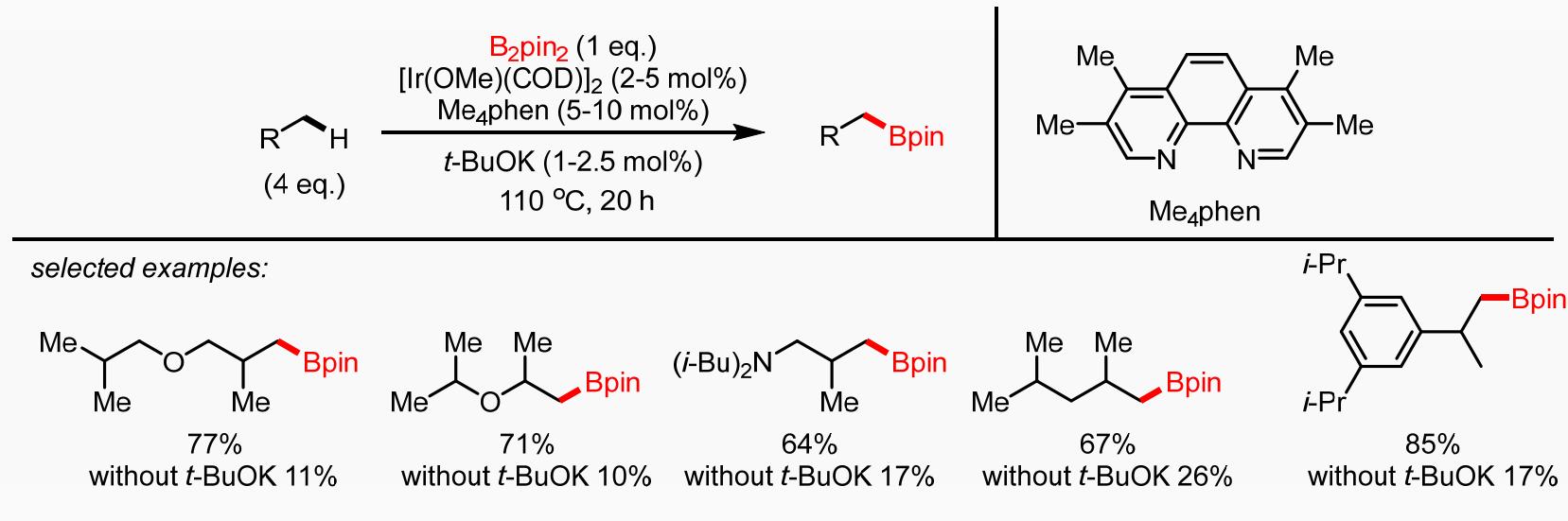
*β-selectivity*

C-H···O interaction	$E_{\text{NBO}}(\text{C-H activation TS})$ (in kcal/mol)	$d(\text{C-O(N)})$ (in Å)	$d(\text{O(N)-H})$ (in Å)	$\angle(\text{C}-\text{H}-\text{O(N)})$
C1-H1···O1	0.7	3.25	2.47	127.1°
C6-H2···O1	0.7	3.36	2.59	126.3°
C3-H3···N	0.7	3.65	2.68	147.8°
C4-H4···O2	2.7	3.19	2.28	139.6°
C5-H5···O3	1.6	3.32	2.39	141.3°

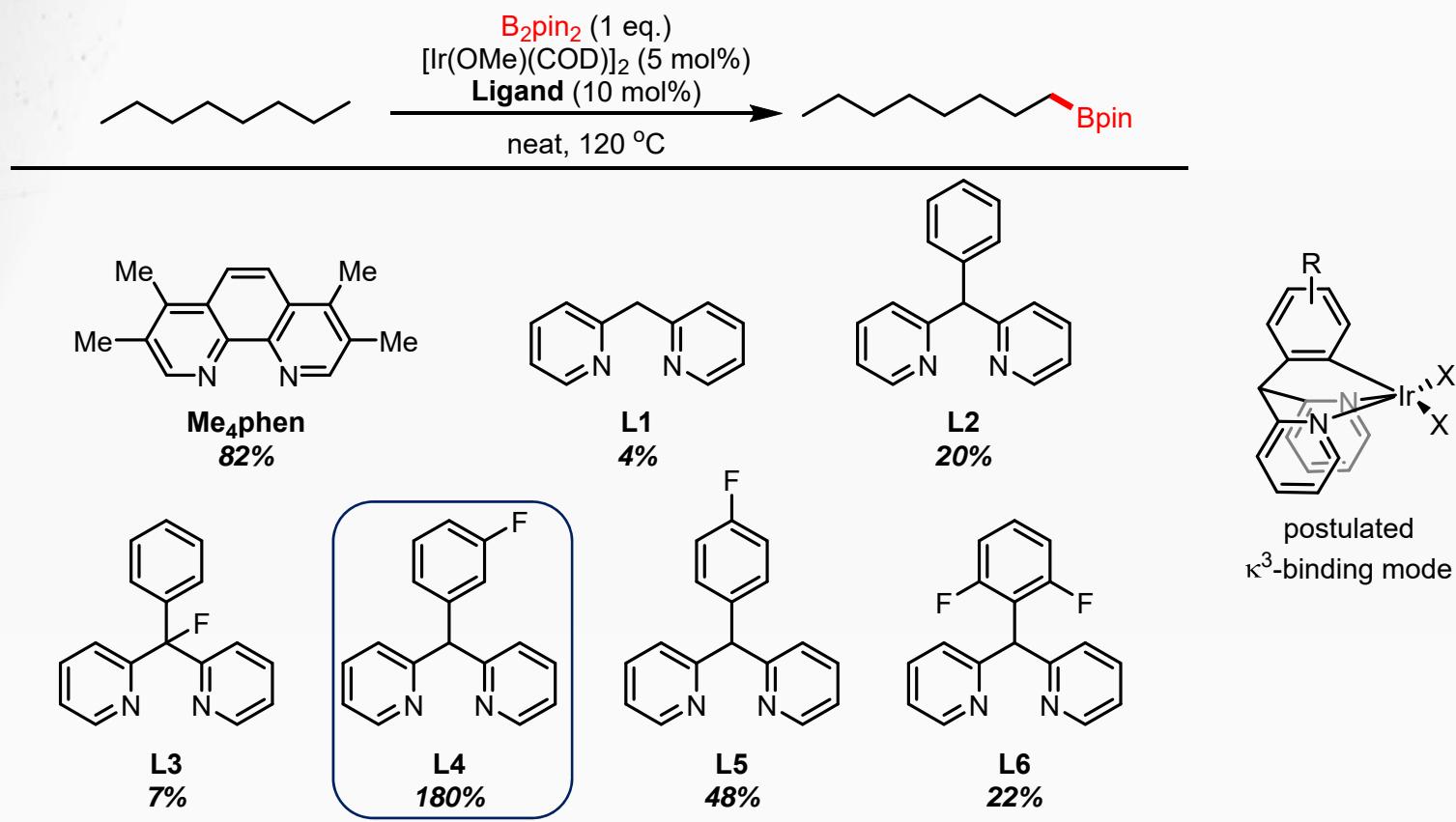
C-H···O interaction	$E_{\text{NBO}}(\text{C-H activation TS})$ (in kcal/mol)	$d(\text{C-O})$ (in Å)	$d(\text{O-H})$ (in Å)	$\angle(\text{C}-\text{H}-\text{O})$
C4-H4···O2	2.4	3.25	2.32	141.8°
C5-H5···O3	0.9	3.35	2.43	142.1°

Hartwig, J. F. et al., *J. Am. Chem. Soc.* 2014, 136, 8755.

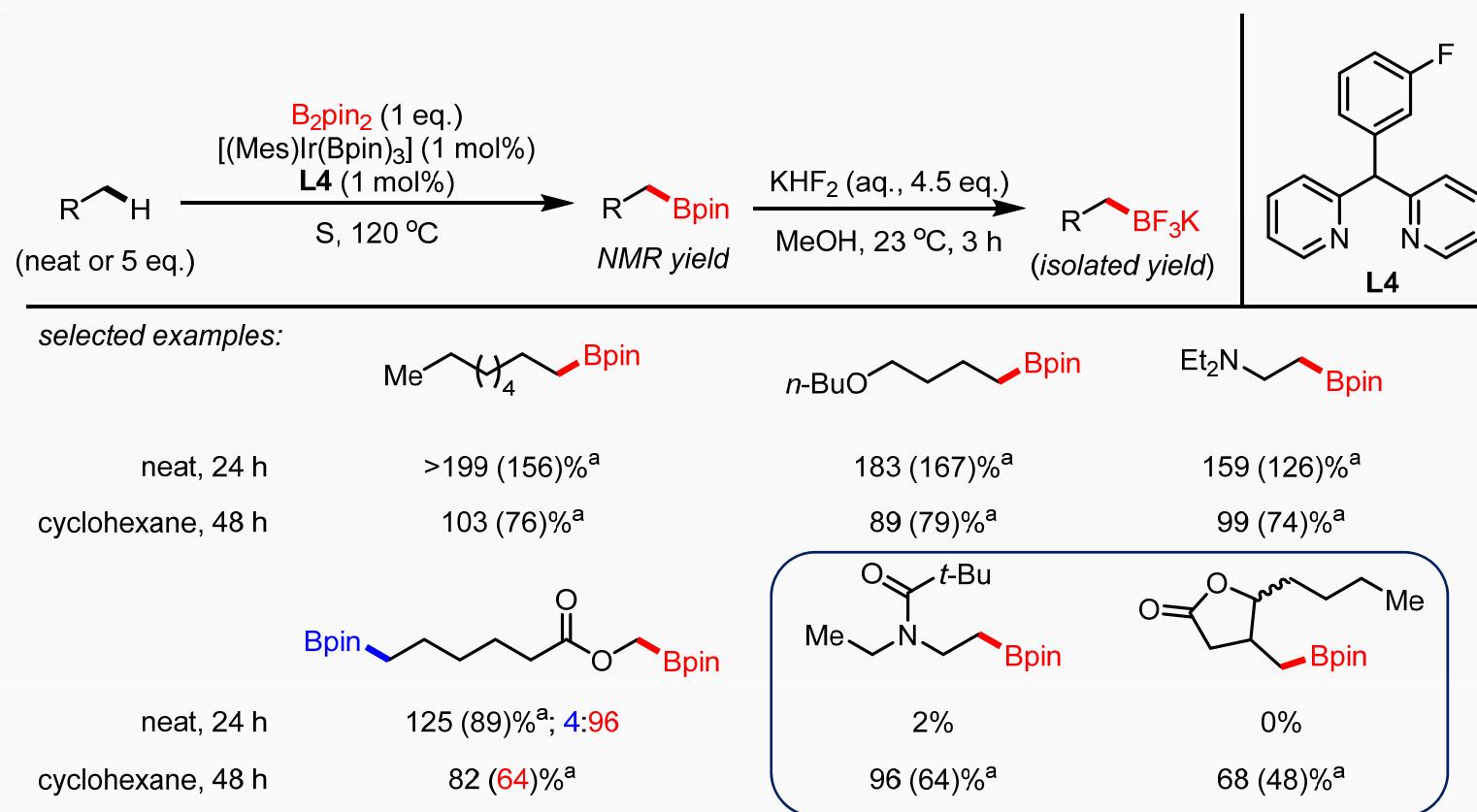
## Borylation of unactivated substrates



## Borylation of unactivated substrates

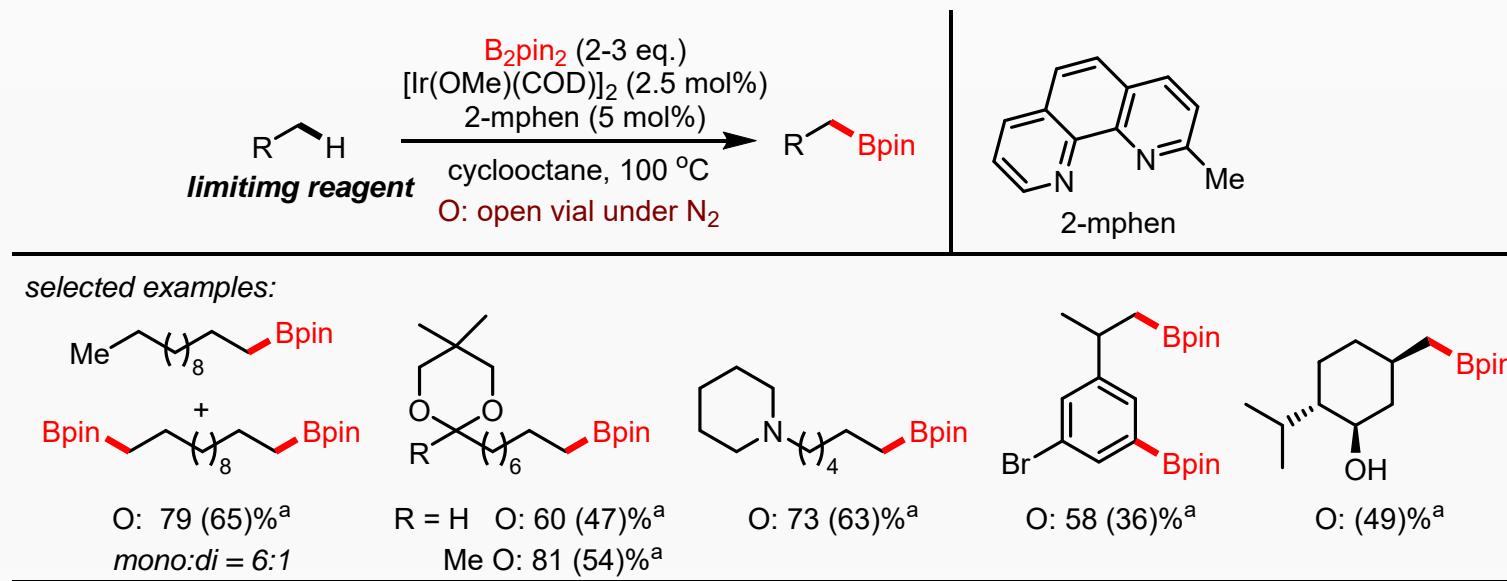


# Borylation of unactivated substrates



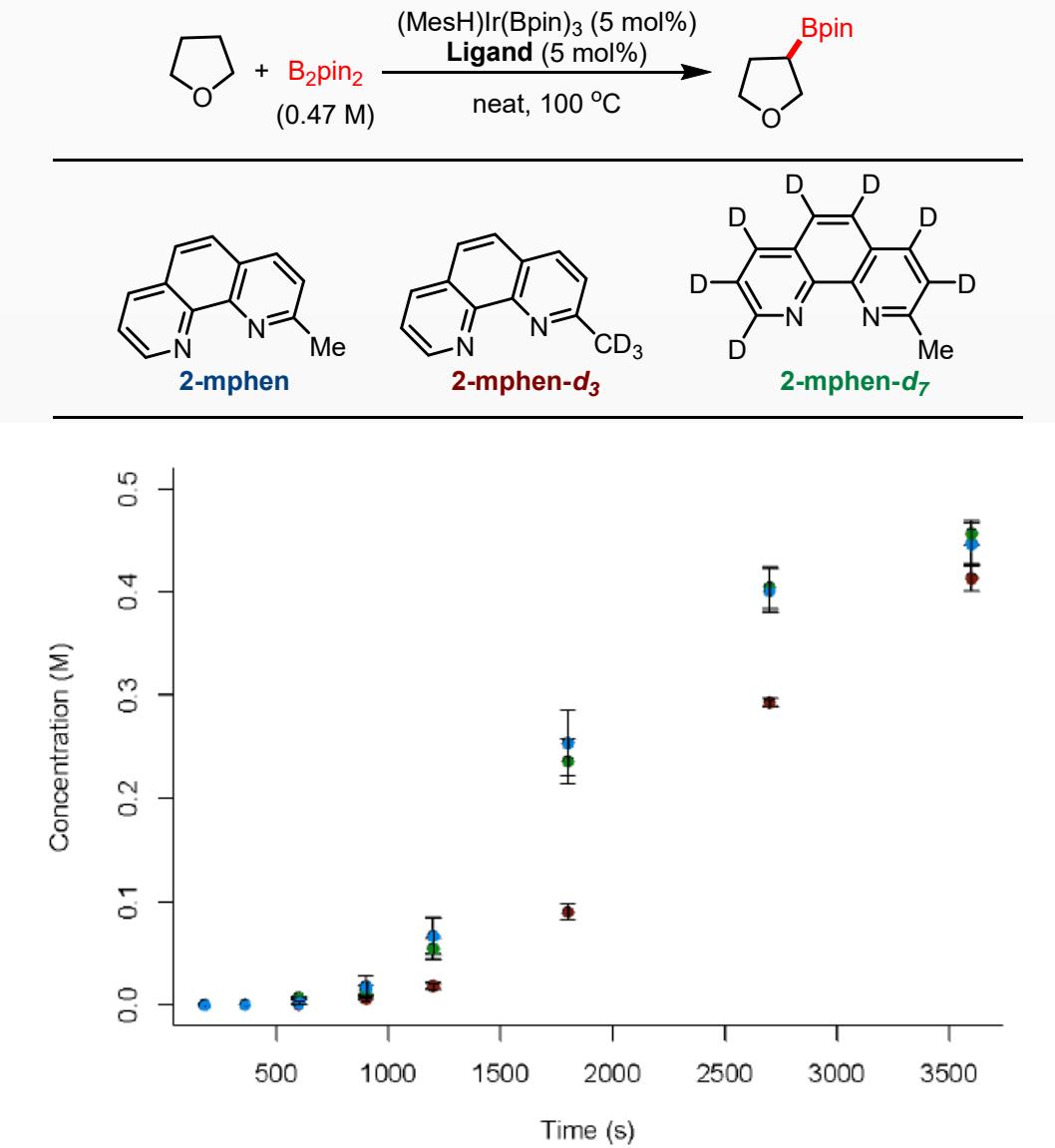
<sup>a</sup> isolated yield in the parentheses.

# Borylation of unactivated substrates



<sup>a</sup> isolated yield in the parentheses.

## Borylation of unactivated substrates



Hartwig, J. F. et al., *Science* **2020**, 368, 736.

# CONTENT >>

01 /

Background

02 /

2.1 Borylation of activated substrates

2.2 Borylation of unactivated substrates

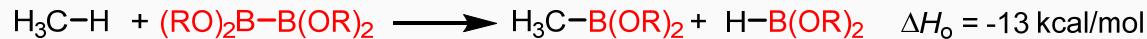
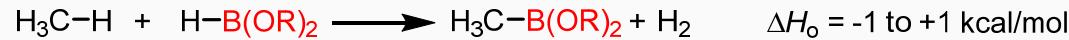
2.3 Borylation of methane

03 /

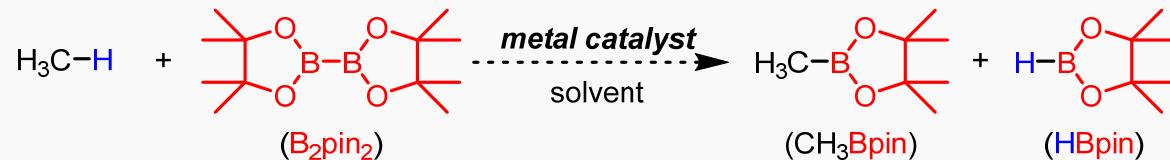
Summary and outlook

# Borylation of methane

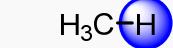
## A Thermodynamics of methane borylation with $B_2(OR)_4$ or $HB(OR)_2$ :



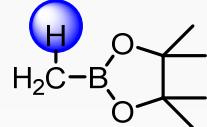
## B Proposed selective mono-C-H borylation of methane:



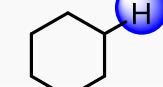
## C Selectivity challenges:



Desired reactant



Initial C-H borylation product



Reaction solvent

**sterically activated**

(most sterically accessible C-H bond)

**electronically activated**

(most acidic C-H bond)

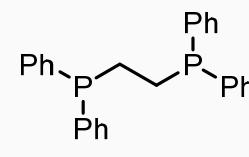
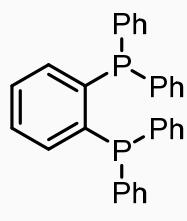
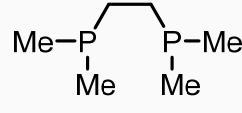
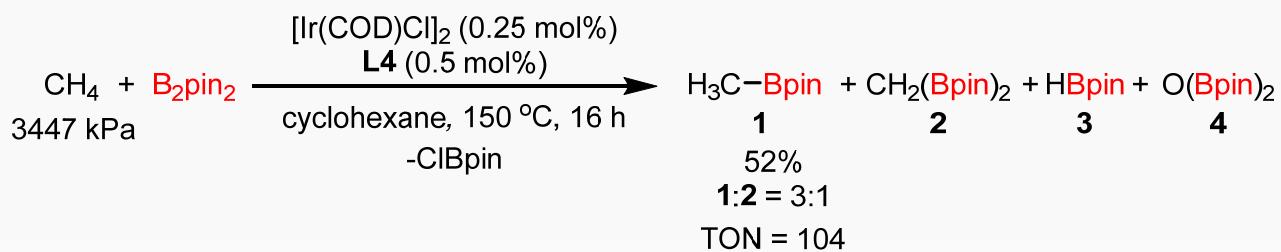
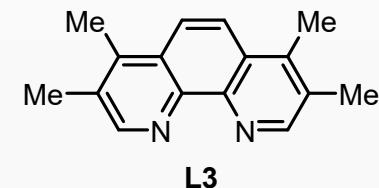
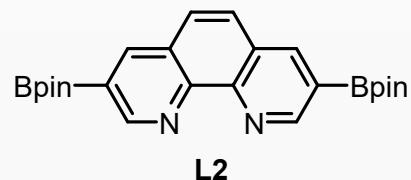
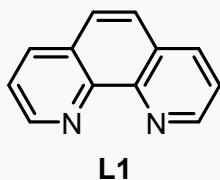
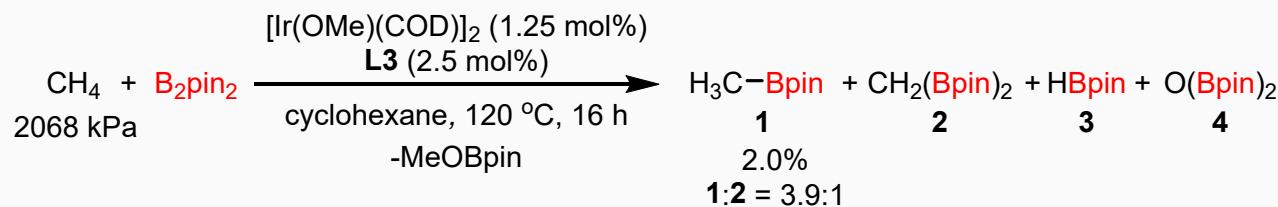
**statistically favored**

(highest concentration C-H bond)

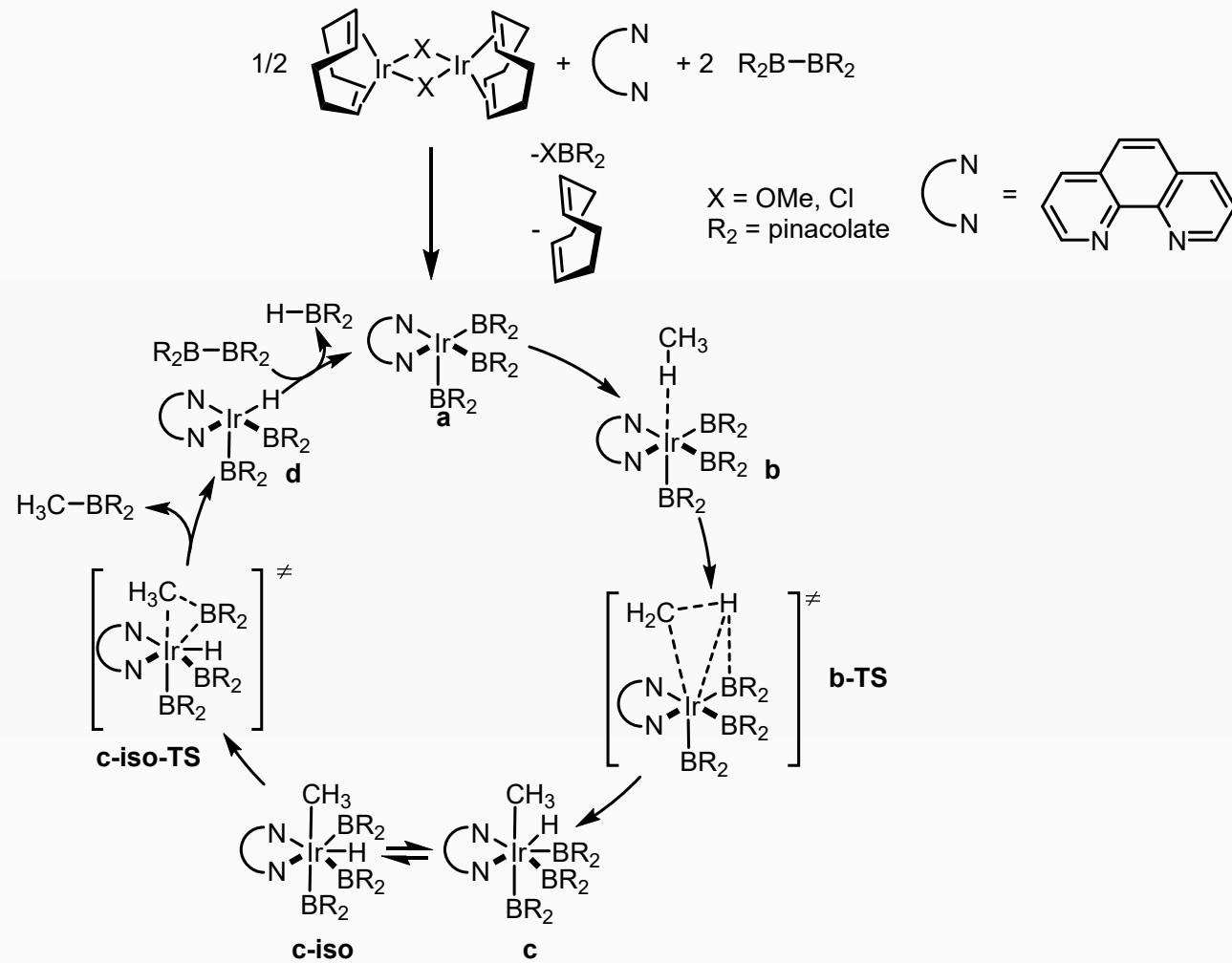
*Poor selectivity  
Overfunctionalization*

*Challenge !*

## Borylation of methane



# Borylation of methane



# CONTENT >>

01 /

Background

02 /

2.1 Borylation of activated substrates

2.2 Borylation of unactivated substrates

2.3 Borylation of methane

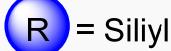
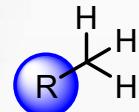
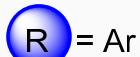
03 /

Summary and outlook

## Summary and outlook

### Summary

Activated substrates:

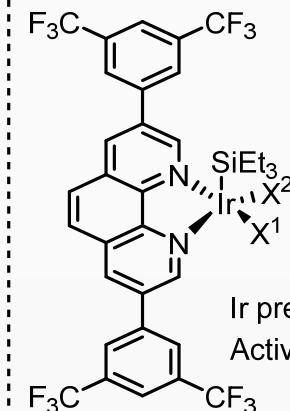


Hartwig, J. F.

An electron-deficient  
phenanthroline as ligand  
 $\rightarrow$   
 $\text{Et}_2\text{SiBpin}$  as reagent

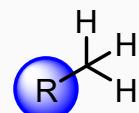
Suginome, M.

$\alpha$ -silyl effect



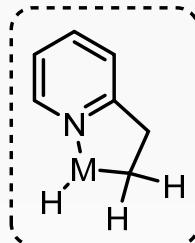
Ir precat:  $X^1 = \text{H}$ ,  $X^2 = \text{Cl}$   
Active cat.  $X^1 = X^2 = \text{Bpin}$

Unactivated substrates :



Directed by N or O

Sawamura, M.  
Sato, Y.



Hartwig, J. F.

$\beta$ -selectivity

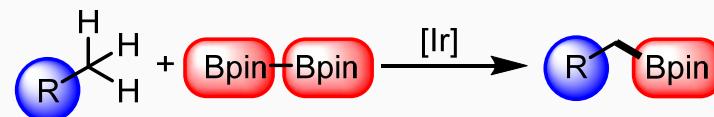
1. Repulsive steric interactions

2. Weak Lewis acid-base interactions

3. C-H...O interactions

## Summary and outlook

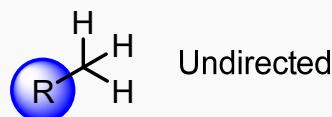
### Summary



Unactivated substrates :

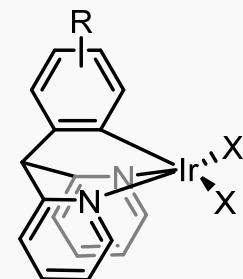
Suginome, M.

cat. *t*-BuOK



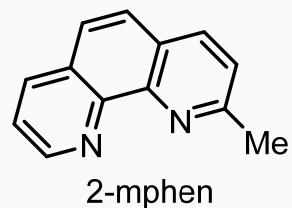
Undirected

Schley, N. D.



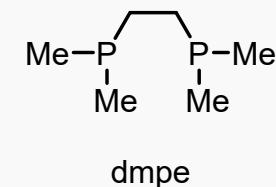
postulated  
 $\kappa^3$ -binding mode

Hartwig, J. F.

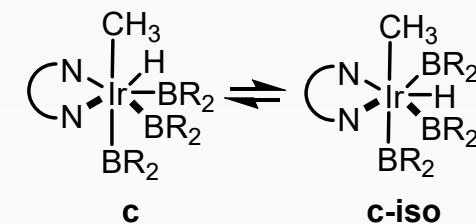


Methane:

Mindiola, D. J.



dmpe



## Summary and outlook

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### *Outlook*

1. The utilization of HBpin
2. The utilization of phosphine ligands
3. The borylation of tertiary C-H bonds
4. Metal-free



*Thanks for your attention*